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Preparation of oriented SiO₃²⁻ doped TiO₂ film and degradation of methylene blue under visible light irradiation

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Abstract

 SiO_3^{2-} doped TiO_2 films with oriented nanoneedle and nanorectangle block structure has been firstly synthesized by hydrothermal synthesis method. The prepared samples are characterized, X-ray diffraction (XRD) results demonstrate that the SiO_3^{2-} doped TiO_2 films are rutile and brookite phases. The scanning electron microscope (SEM) analysis reveals that the quantity of O_2 affects the morphology of the SiO_3^{2-} doped TiO_2 films (SiTiA films prepared with unmodified substrate). The SiO_3^{2-} doped TiO_2 films (SiTiB films prepared with modified substrate) display two layers, one is porous structure, the other is nanoneedle structure. UV–vis, IR, transmission electron microscopy (TEM) and energy-dispersive X-ray (EDX) microscopy all prove that SiO_3^{2-} have been doped in the TiO_2 crystal structure. They have remarkable red shift and higher photocatalytic activity of degradation of methylene blue than P-25 under visible light ($\lambda > 420$ nm) irradiation. Besides, photocatalytic activity of the film is stable during 4 times recycling.

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Keywords: SiO₃²⁻ doped TiO₂ films; Hydro-thermal synthesis methord; Photocatalytic activity; Red shift

1. Introduction

Titanium dioxide (TiO₂) has been extensively used as the photocatalytic material due to its self-cleaning [1–4], purifying [5–7] and antibacterial [8,9] properties. Photocatalytic degradation of remanent chemical contaminants in waste water and atmosphere on TiO₂ surface under UV irradiation offers an effective approach to settle various environmental problems [10,11]. However, the reactivity of TiO₂ mostly relies on UV light while there is only 5% UV light in the solar spectrum, which enormously limits the using efficiency of sunlight [12,13]. Harvesting more sunlight for photocatalytic or photoelectrochemical purposes will be enormously enhanced by extending the photoresponse of TiO₂ into the visible spectral range.

Recent theoretical and experimental studies have shown that the desired band gap narrowing of TiO₂ can be achieved using nonmetal atoms dopants to enhance the photoactivity of TiO₂ in the visible spectral range, such as N [14,15], I [16,17], and S [18]. Gole [15] prepared catalytically active $\text{TiO}_{2-x}\text{N}_x$ structured particles whose absorption onset extended well into the visible region at 550 nm. Sandro et al. [16] prepared $(I_2)_n$ encapsulation inside TiO_2 that a broad absorption band appeared in the interval between 400 nm and 667 nm. However, there has been few reports on the modification of TiO_2 with acid radical, such as SiO_3^{2-} , to achieve red shift.

Furthermore, the application of powdered TiO₂ as a photocatalyst in wastewater treatment had the drawback of post-separation in a slurry system after photoreaction. Therefore, attempts have been made to immobilize the TiO₂ in the form of thin films on different rigid substrates, such as glass [19,20] which is available and possesses good light-admitting quality substrate and quartz [21]. Bolunt et al. [19] prepared transparent thin-film TiO₂ layer by sol–gel deposition method on Pyrex reactor which was showed to be more active for photocatalytic oxidation of acetaldehyde, acetic acid and toluene than Degussa P-25 thin films under UV light. Mi et al. [21] prepared N-doped TiO₂ films on quartz by calcining the TiO₂ films in ammonia atmosphere. Eiji et al. [22] firstly reported an evolution of a new morphology of film consisting of

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highly crystalline (nearly single-crystalline) rectangular parallelepiped rutile TiO₂ in a submicrometer scale. It is regretful that there was no application for the films.

In this paper, SiO_3^{2-} doped TiO_2 films were firstly fabricated by one simple step without using any templates or additives which was easy to be applied in practice. The films are beautiful with oriented nanorectangle block and nanoneedle structure. UV–vis, IR, TEM and EDX all prove that SiO_3^{2-} have been doped in the TiO_2 crystal structure.

2. Experimental

2.1. Treatment of subtrates

The glass slides were treated as substrates with two different ways. One way, the glass slides were cleaned with deionized water and unmodified. The SiO₃²⁻ doped TiO₂ films which were prepared with this kind of substrates denoted as SiTiA films. Another way, the glass slides were cleaned with 1.0 M HCl and ethanol solution in an ultrasonic bath. After dried at 373 K, the glass slides were placed in Teflon-lined autoclaves which were filled with deionized water. Then the autoclaves were heated at 448 K for 8 h. After hydrothermal treatment, the glass slides were washed with deionized water several times and dried at 308 K [23]. The SiO₃²⁻ doped TiO₂ films which were prepared with this modified substrates denoted as SiTiB films.

2.2. Preparation of SiO_3^{2-} doped TiO_2 films

The ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ films were synthesized via hydrothermal treatments of aqueous titanium trichloride (TiCl₃; 6 mL) solution and sodium silicate (NaSiO₃; 0.060 M) solution. The solutions and previous treated substrates were placed in Teflon-lined autoclaves which were filled with a certain amount of O₂. Then Teflon-lined autoclaves were heated at 473 K for typically 4 h. The resultant films were rinsed with deionized water and dried at 308 K (the film noted as SiTi film).

2.3. Characterization

The structure and phase identification were characterized by X-ray diffraction (XRD) patterns which were recorded on D/Max Rigaku diffractometer using Cu K α radiation (λ = 0.1542). The surface morphologies were examined by scanning electron microscope (SEM, KYKY-2800B). The samples were coated with gold to make conducting before put into the SEM chamber. The film segments scraped from the glass slides were characterized by transmission electron microscopy (TEM) with an energy-dispersive X-ray spectrometer (a Tecnai G² F30 S-Twin transmission electron microscopy). FTIR spectras of SiO₃²⁻ doped TiO₂ were measured to investigate structural information and specific molecule-groups information (a Bruker EQUINOX55 spectrometer). UV-vis diffuse spectra were obtained on a JASCO V-55O spectrometer with BaSO₄ for reference.

2.4. Measurement of photocatalytic activity

The photocatalytic activity of the samples was evaluated by photodegrading methylene blue, because methylene blue was one of the most typical persistent organic pollutants. Photocatalytic experiments were carried out in a homemade reactor which was surrounded by a cooling system to keep room temperature of the reaction system. A 300-W iodine tungsten lamp was used as the light source and photocatalytic activity of SiO₃²⁻ doped TiO₂ films were tested by visible light that any irradiation below 420 nm was removed by a cutoff filter. Photodegradation of methylene blue (20 mg/L) was carried out in a jacketed cylinder which was stirred by a magnetic stirrer in the below and illuminated in the right. The distance between light source and the surface of the solution was 16 cm. The solution was kept in the dark for 0.5 h to establish an adsorption-desorption equilibrium before the visible light radiation. The concentration of the methylene blue solution was determined on the basis of its characteristic optical absorption at 665 nm on a 721 spectrophotometer.

3. Results and discussion

3.1. XRD analysis

Fig. 1 shows the X-ray diffraction (XRD) pattern of the SiTiA film. The crystalline phases are confirmed rutile and brookite [22]. All the diffraction peaks agree with those of TiO_2 in the rutile and brookite forms, meanwhile the [1 1 0] and [1 0 1] axises of SiTiB film are enhanced. The difference in the peak intensity ratio is caused by orientation.

3.2. SEM analysis

Fig. 2 shows scanning electron microscope (SEM) images of SiTi films. The morphology of the SiTiA film (Fig. 2b) appears to be nanorectangle block which was prepared with a little of O₂. Surprisingly the morphology is changed to be nanoneedle (Fig. 2a) when it was prepared with a lot of O₂. So these results

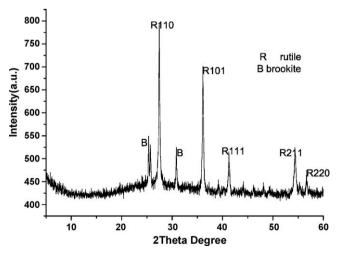


Fig. 1. XRD pattern of the sample SiTiA film.

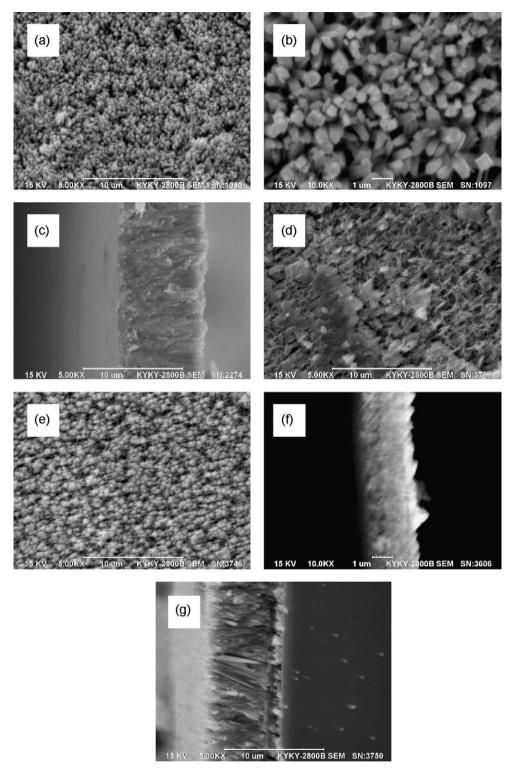


Fig. 2. SEM images of the SiO_3^{2-} doped TiO₂ film. (a and c) SiTiA film prepared with a lot of O₂. (b) SiTiA film prepared with a little of O₂. (d and f) The film formed by treating glass with hydrothermal synthesis. (e and g) SiTiB film prepared with a lot of O₂.

show that the quantity of O_2 affects the morphology of the SiTiA films. And with O_2 increasing, the nucleations become more on some spots of the substrate surface, resulting to grow nanoneedle which takes up less area. Besides, as shown in Fig. 2c, the SiO_3^{2-} doped TiO_2 film tightly grows perpendicularly on the glass substrate and the thickness is approximately

 $8~\mu m$, which is enough thick to acquire visible light and induce photoproduction electron and photoproduction hole. The cross-section of the film appears to be oriented and vicelike which is still tight on the substrate after 4 times recycling. The probable reason is that ${\rm SiO_3}^{2-}$ in ${\rm TiO_2}$ film has successfully formed Si–O–Si bonds with Si in the glass. At the same time, as shown in

Fig. 2d and f, the film fabricated by modified glass substrate with hydrothermal synthesis displays porous structure and the thickness of the film is about 2 μ m. According to Ho et al. [23], the chemical composition analysis using energy-dispersive X-ray (EDX) spectroscopy illustrates that the film mainly contain Si, O, Ca, Al and Mg, without Na which was instead in the process of hydrothermal synthesis. The SiTiB film (Fig. 2e) which was prepared with a lot of O_2 also appears to be nanoneedle structure and the thickness of film is about 8 μ m (Fig. 2g). The thickness of SiO₃²⁻ doped TiO₂ film is approximately 6 μ m and the interface of two layers is evident.

The SEM analysis reveals that the quantity of O_2 affects the morphology of the SiTiA films and the TiO_2 nanocrystals have preferred orientation with most of their tips roughly pointing upward. Moreover, significantly enhanced peaks of both (1 1 0) and (1 0 1) reflections further confirm that a preferred [0 0 1]-oriented SiO_3^{2-} doped TiO_2 film is perpendicular to the substrate. The SiTiB films with modified substrate display two layers, one is porous structure, the other is nanoneedle structure.

3.3. FTIR analysis

The Fourier transform infrared absorption (FTIR) spectra of SiTiA film and P-25 (Degussa) are shown in Fig. 3. It is reported that the high-frequency part of the spectra is dominated by the OH stretching vibration (3100–3500 cm⁻¹) and bending vibration (1640 cm⁻¹) of water. The peaks at about 2920 cm⁻¹, 600–700 cm⁻¹, 1110 cm⁻¹ correspond to Ti, Ti–O and unsymmetry stretching vibration of Si–O–Si, respectively. Two absorption bands near 1036 cm⁻¹ and 930–970 cm⁻¹ can be ascribed to the stretching vibration of SiO₃²⁻ and Ti–O–Si respectively [24–26]. The above results illustrate that SiO₃²⁻ phase doped in TiO₂ matrix and form partially Ti–O–Si group in the matrix of TiO₂.

3.4. UV-vis diffuse spectra analysis

Fig. 4 illustrates the UV-vis diffuse reflection spectra of sample SiTiA film, P-25 (Degussa) and glass (substrate). The

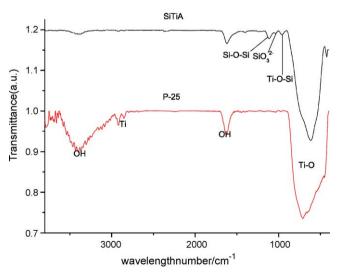


Fig. 3. FTIR spectra of sample SiTiA film and P-25 (Degussa).

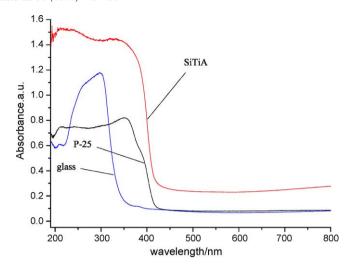


Fig. 4. UV-vis diffuse spectra of SiTiA film, P-25 and glass.

synthesized sample SiTiA films demonstrate more drastic and stronger photoabsorption in the visible light range from 400 to 550 nm than P-25. SiO_3^{2-} doped TiO_2 film can shift the absorption edge of TiO_2 to the visible light range and narrow

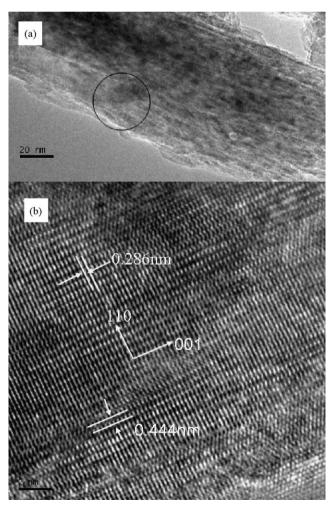


Fig. 5. TEM images (a) a low magnification image of SiTiA film prepared with a lot of $\rm O_2$ and (b) a high-resolution transmission electron microscope (HR-TEM) image of SiTiA film.

the band gap. Zhang et al. [27] reported the small blue shift of 20% silica/TiO₂ composite membrane. That mainly ascribed to the formation of small TiO₂ particles by embedding of amorphous silica into the TiO₂ matrix. Zhang et al. [26] also reported the SiO₂-doped TiO₂ appeared to be obvious blue shift in the absorbing band edge. Here, from the UV–vis diffuse spectra, it has remarkable red shift so further confirms SiO₃²⁻ doped in TiO₂ crystal structure and excludes mechanical mixture of TiO₂ with SiO₂. The absorption intensity of SiTiA film was obviously higher than that of P-25, which would be beneficial for photocatalytic degradation of organic pollutants under visible light irradiation [27].

3.5. TEM analysis

Fig. 5 shows transmission electron image of SiTiA films. A low magnification of SiTiA film prepared with a lot of O₂ is showed in Fig. 5a corresponding to it is high-resolution transmission electron (Fig. 5b). The distances between the adjacent lattice fringes can be assigned to the interplane distance of rutile TiO₂ (001) and (110), which are $d_{0\ 0\ 1} = 0.286 \text{ nm}$ and $d_{1\ 1\ 0} = 0.444 \text{ nm}$. The latter Lattice distance is bigger than pure TiO_2 $d_{1\,1\,0} = 0.325$ nm. It is ascribed to SiO₃²⁻ doped in TiO₂ crystal structure. The [1 1 0] axis was perpendicular to the wall. The crystals therefore grew along the [0 0 1] axis, which was perpendicular to the [1 1 0] axis. These findings explain the above-mentioned orientation of the film according to XRD and SEM results. SiO₃²⁻ doped TiO₂ film appears to be nanoneedle in Fig. 6a. EDX (energy dispersive X ray fluorescence) image of SiTiA film (Fig. 6c which is corresponding to the area in Fig. 6a) reveals that there is only Si element in TiO₂ crystal structure and free from Na or Cl element which further proves that SiO₃²⁻ have been doped in the TiO₂ crystal structure. Copper ions come from the copper web. Fig. 6d and e are EDX energy maps of Ti element and Si Without NaSiO₃, the tightly and orientedly TiO₂ film is difficult to form and easy to be polished off. When NaSiO₃ is replaced by NaS₂O₃·5H₂O, KNO₃ or NaIO₃, the TiO₂ film is also difficult to form. The above results illustrate that NaSiO₃ is the appropriate choice in fabricating the film. These SiO₃²⁻ ions likely serve as the nucleation sites for the rutile crystals. Based on the titanyl silicate structure, the silicate tetrahedra prefers binding to the vertexes of the Ti-O octahedral [28]. The latter group of negative ions is easy to acquire electron, TiCl₃ mixed with them, Ti (III) is quickly changed to Ti (IV). Moreover, the film could not be fabricated when using aqueous TiCl₄ solution under the same experimental conditions. When using Ti (IV) instead of Ti (III) as the Ti source, it quickly hydrolyzes into Ti(OH)₄ when mixed with H₂O (4). And Ti(OH)₄ space resistance is very great. Even though reacting with NaSiO₃, it is not stable and easily removes H₂O molecule and forms TiO₂ crystal when it is heated (5). Another important point, gradual growth is necessary for the formation of crystal system. The rate of reaction of Ti (IV) in forming TiO₂ is too fast to permit to control thermodynamic equilibrium to be attained [29].

So the film could not be fabricated when using aqueous $TiCl_4$ solution under the same experimental conditions. The film deposition is found to be promoted in the oxygen-saturated solution, while the nitrogen saturated solution can not lead to the formation of the rutile film [22]. The process of Ti (III) being slowly oxided into Ti (IV) by O_2 well controls supersaturation. So that SiO_3^{2-} doped TiO_2 films is successfully fabricated. In a word, Ti (III), stable acid radical and O_2 are the crucial elements in fabricating the film.

$$Ti^{3+} + H_2O = TiOH^{2+} + H^+$$
 (1)

element respectively corresponding to Fig. 6b. The distribution of Si element is similar to the distribution of Ti element. Si element is essentially dispersed in TiO₂, not get together.

3.6. Mechanism

The probable chemical reaction mechanism is as follow: TiCl₃ quickly hydrolyzes into TiOH²⁺ when it mixed with H₂O (1) [22]. Then adding NaSiO₃, TiOH²⁺ reacts with it and forms Ti²⁺OSiOONa (2). Since TiOH²⁺ space resistance is very small, it has chance for SiO₃²⁻ to form Si-O-Ti bond. Although Ti (III) is slowly oxided to Ti (IV) by O₂ at 473 K, Ti-O-Si bond is still stable, meanwhile combing with glass substrate, ultimately forming SiO₃²⁻ doped TiO₂ film on the substrate (3) [28].

$$Ti^{4+} + 4H_2O = Ti(OH)_4 + 4H^+$$
 (4)

$$Ti(OH)_4 = TiO_2 + 2H_2O$$
 (5)

3.7. Photocatalytic properties of SiTi films

In this report, the photocatalytic properties of SiTiA film and SiTiB film were examined. Fig. 7 shows the area of film on the substrate. When the substrate was placed in the Teflon-lined autoclave, only the area of $4.5 \text{ cm} \times 2.5 \text{ cm}$ was immerged in the reactive solution. When it was took out form the Teflon-lined autoclave after 473 K for 4 h, the area of $3.3 \text{ cm} \times 2.5 \text{ cm}$

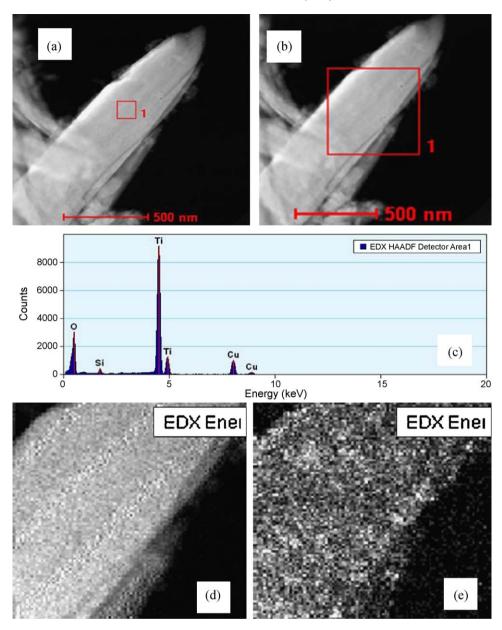


Fig. 6. STEM and energy-dispersed X-ray (EDX) spectroscopy images of SiTiA film. (a) STEM image of SiTiA film, (b) STEM image of SiTiA film, (c) EDX image of SiTiA film corresponding to (a), (d) EDX energy map of Ti corresponding to (b), (e) EDX energy map of Si corresponding to (b).

grew film. The bottom substrate was difficult to form film, because the bottom O_2 was deficient moreover there was much precipitation covered the substrate. As a result, the effective photocatalytic area of film was approximately $3.0~\rm cm \times 2.5~cm$ (Fig. 7).

To compare the photocatalytic activity of commercial TiO_2 (P-25), SiTiA film and SiTiB film, photodegradation of methylene blue as a test reaction was performed according to procedure reported in the literature [30]. 0.06 g P-25 photocatalyst was suspended in 60 mL metheylene blue solution (20 mg/L) under stirring magnetically, while SiTi film with the area of 3.0 cm \times 2.5 cm immersed in 60 mL metheylene blue solution (20 mg/L) under stirring magnetically. Under visible light (λ > 420 nm), samples of SiTiA (Fig. 8b) and SiTiB (Fig. 8c) shows much better photocatalytic activity than P-

25 (Fig. 8d). The difference in photocatalytic activity between P-25 and SiTi films can be ascribed to greatly high absorbance in the visible light range (between 420 and 550 nm) of the latter, although there is wide gap of surface area between them $(51~\text{m}^2~\text{g}^{-1}\times0.06~\text{g}=3.06~\text{m}^2)$ for P-25 which can full contacted with methylene blue in powder vas $0.03~\text{m}\times0.025~\text{m}=0.00075~\text{m}^2$ which is the area of substrate covered with SiTi film for the latter). The superiority of SiTi film is ascribed to greatly high absorbance in the visible light range (between 420 and 550 nm) which plays a crucial role in the experiments. The photocatalytic activity of SiTiA film (Fig. 8b) and SiTiB film (Fig. 8c) is same. A porous structure actually enlarge surface area of substrate. Due to the morphology of SiO₃²⁻ doped TiO₂ film is nanoneedle, the surface area of film has not been greatly enlarged. Besides the thickness of the

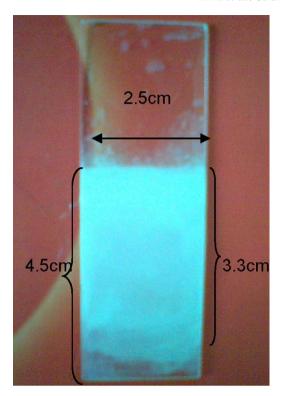


Fig. 7. The area of film covered on the glass.

 ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ film of SiTiB film (Fig. 8c) is thinner than SiTiA film (Fig. 8b). Therefore, the photocatalytic activity of SiTiB film (Fig. 8c) is not advanced. The photocatalytic activity of SiTiA film (Fig. 8a) without light cutoff filter is better than SiTiA film (Fig. 8b) with cutoff filter. That illustrates that ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ film can also absorbed UV light. The photocatalytic activity of SiTiA film (Fig. 8e) is a little worse than SiTiA film (Fig. 8b). That is because that SiTiA film (Fig. 8b) with the morphology of nanoneedle had lager surface than SiTiA film (Fig. 8e) with the morphology of nanorectangle block.

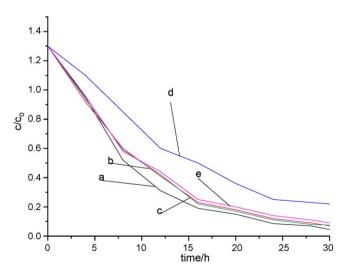


Fig. 8. Photodegradation of methylene blue by using (a) SiTiA film without cutoff filter. (b) SiTiA film prepared with a lot of O_2 with cutoff filter. (c) SiTiB film with cutoff filter. (d) P-25 with cutoff filter. (e) SiTiA film prepared with a little of O_2 with cutoff filter.

Table 1
The recycling photodegradation rate (%) of SiTiA film.

| Samples | 1 | 2 | 3 | 4 |
|---------|------|------|------|------|
| SiTiA | 96.7 | 96.0 | 95.2 | 96.1 |
| SiTiB | 96.7 | 95.5 | 93.0 | 90.0 |

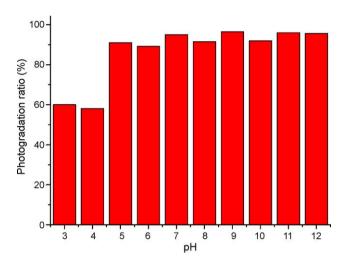


Fig. 9. The effect of pH on methylene blue degradation.

Table 1 illustrates that the average of the four times recycling photodegradation rate of SiTiA film prepared with a lot of O_2 is about 96.0%. Photocatalytic activity of the film is very stable after 4 times recycling. However, photocatalytic activity of SiTiB film is decreased. Because the interface of two layers is not stable when immersed in methylene blue for long time.

3.8. Effect of pH

The pH of the solution is one of the most important controlling parameters in the degradation of methylene blue on semiconductor metal oxides. The wastewater from textile industries usually has a wide range of pH values. When pH > 5, the percentage of degradation is stable; while pH < 5, the percentage of degradation decreases (Fig. 9). PH effect can be explained on the basis of point of zero charge of $\mathrm{SiO_3}^{2-}$ doped $\mathrm{TiO_2}$. The PH_{pzc} of $\mathrm{SiO_3}^{2-}$ doped TiO₂ is above 4.0. At pH values higher than 4.0, the surface become negative charge, and the opposite occurs for pH values greater than PH_{pzc}. Since methylene blue is a cationic dye, it is conceivable that high pH adsorption is favored on a positively charged surface and hence the reaction is faster at alkaline pH.

4. Conclusions

 ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ films with oriented nanoneedle and nanorectangle block structure has been firstly successfully fabricated by hydrothermal synthesis method. XRD results demonstrate that the ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ films are rutile and brookite phases. The SEM analysis reveals that the quantity of ${\rm O_2}$ affects the morphology of the SiTiA films films. The films

are very vicelike and the thickness is about 8 μ m. SiTiB films with modified substrate display two layers, one is porous structure, the other is nanoneedle structure. UV–vis, IR, TEM and EDX all prove that ${\rm SiO_3}^{2-}$ have been doped in the ${\rm TiO_2}$ crystal structure. They have remarkable red shift and higher photocatalytic activity of degradation of methylene blue than P-25 under visible light ($\lambda > 420~{\rm nm}$) irradiation. Besides, photocatalytic activity of the film is stable during 4 times recycling. Analyse the reaction mechanism and conform that Ti (III), stable acid radical and ${\rm O_2}$ are the crucial elements in fabricating the film. This ${\rm SiO_3}^{2-}$ doped ${\rm TiO_2}$ films will be very useful as photocatalyst to settle various environmental problems, because the present hydrothermal synthesis technique is very simple and inexpensive, meanwhile the material and substrate are very cheap.

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